

The Albanova Nano Fabrication Facility

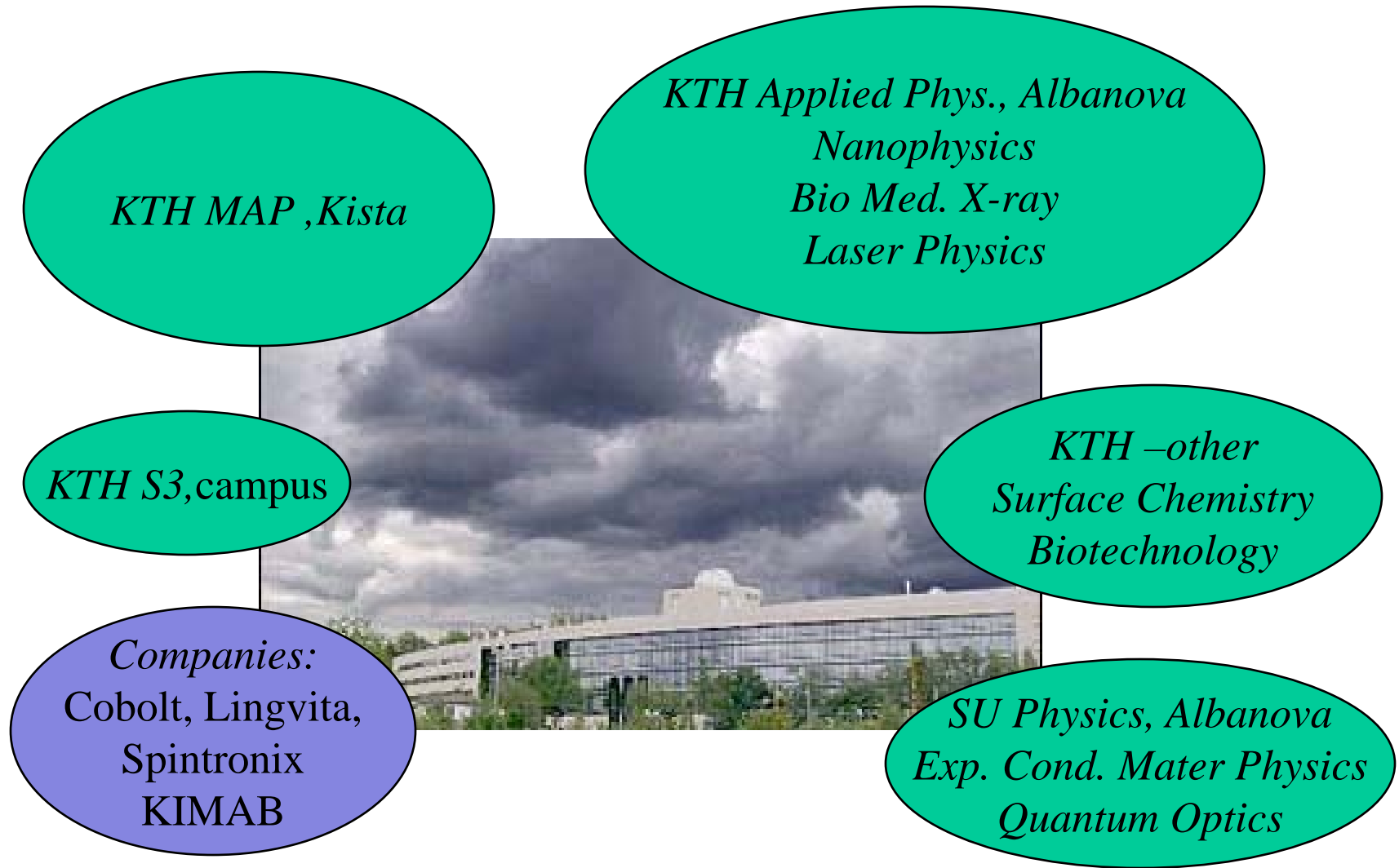
Nano technology for basic research
and small commercial enterprises

Director: Prof. David Haviland

Nano-Lab Philosophy

- Nanometer scale patterning and metrology
- Broad spectrum of user research, stimulate new ideas
- Graduate students post docs are users, help maintain
- Small technical staff, minimal administration
- Flexible environment for basic research
 - Direct writing techniques, small series production
- Wide variety of materials
- Small format for machines

Used by many institutions in Stockholm



Funding:

Phase 1: 9 M SEK K A Wallenberg

Phase 2: 10 M SEK K A Wallenberg

Phase 3: 7 M + 3M SEK K A Wallenberg +VR

(+ ca 4.5 M SEK: VR, G. Gustafsson, KTH Start-up, Misc.)

5 Laminar flow benches

2 Photo
Lithography

Wet bench, hood

Surface Profilometer

E-beam lithography

Scanning Probe Microscope

Scanning Electron Microscope
Focused Ion Beam System

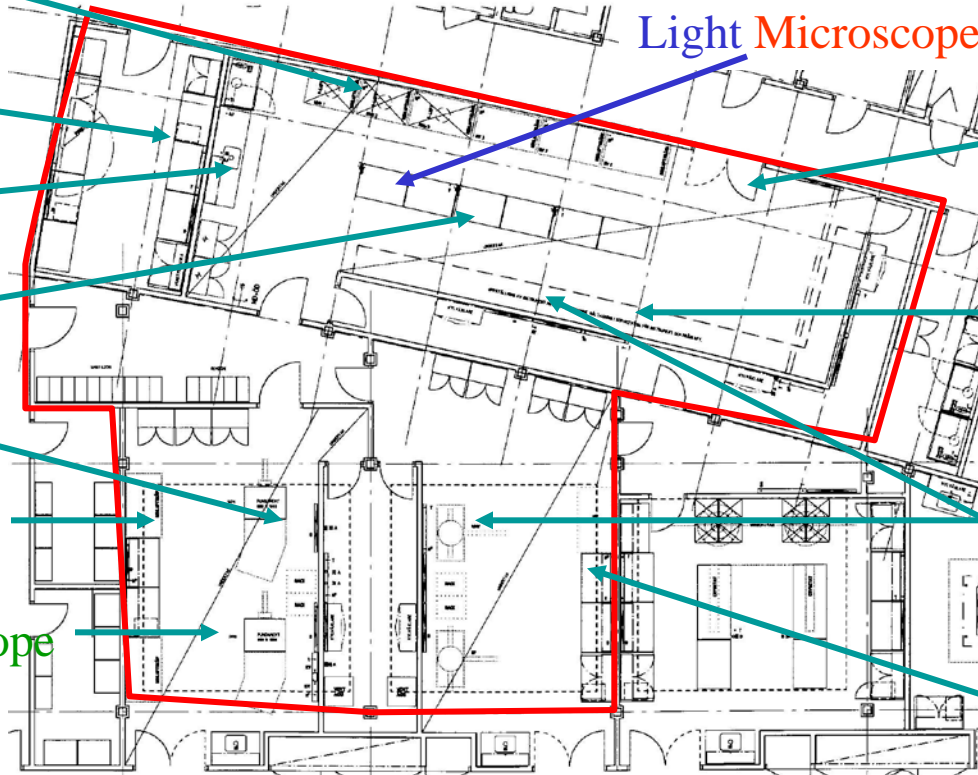
Light Microscopes

Various Ovens

3 Reactive Ion
Etchers

4 Vacuum
Deposition
Systems

Wire Bonder



345 m² total - 285 m², clean room 500 - 2000 part. / ft³
Lab coat , hair net, latex gloves, clean benches



Equipment

[E-beam lithography](#)[Booking](#) [FBMS upgrade](#)[Dual beam system](#)[Booking](#)[SPM/AFM/STM](#)[Booking](#)[Profilometer](#)[RIE, Ar, O₂](#)[RIE, BCl₃, Cl₂](#)[Mask aligner](#)[Booking](#)[Projection mask aligner](#)[Multi target Sputtering](#)[System](#)[UHV E-gun sputtering](#)[HV E-gun deposition](#)[Booking](#)[UHV E-gun / Ion gun](#)[Bonder](#)[Laminar flow benches](#)[Optical microscope, DIC, DF](#)[Opt. micr. 5 Mpix camera](#)[Opt. micr., yellow lab](#)[Fluor. micr. w. cooled CCD](#)[Stereoscope](#)[Resist spinner](#)[Resist spinner #2](#)[Hotplate](#)[Hotplate #2](#)[Clean water](#)[Carbon coater](#)[Evacuated oven](#)[Ultrasound, vari-power](#)

Useful links

[Usage and Safety](#)[Activity Report \(pdf\)](#)[Resist data](#) [limited access](#)[Clean-room particle count](#)[Nano-Fab-Lab Wiki](#)[NanoFabLab users, phonelist](#)[Service and labs, phonelist](#)[Chemical database](#)

- Joint KTH SU laboratory facilities, with broad user spectrum
- Nano and micro scale fabrication, imaging and metrology
- Graduate students and post docs are users
- Low overhead costs, flexible lab environment for exploratory research

KTH Applied physics and SU Physics jointly run this facility located in [AlbaNova University Center](#) There are about 30 active users from several departments at KTH and SU. If you are interested in access, contact director [Prof. David Haviland](#) or manager [Dr. Anders Liljeborg](#).

Most of the equipment has been financed by grants from the [K. A. Wallenberg Foundation](#).

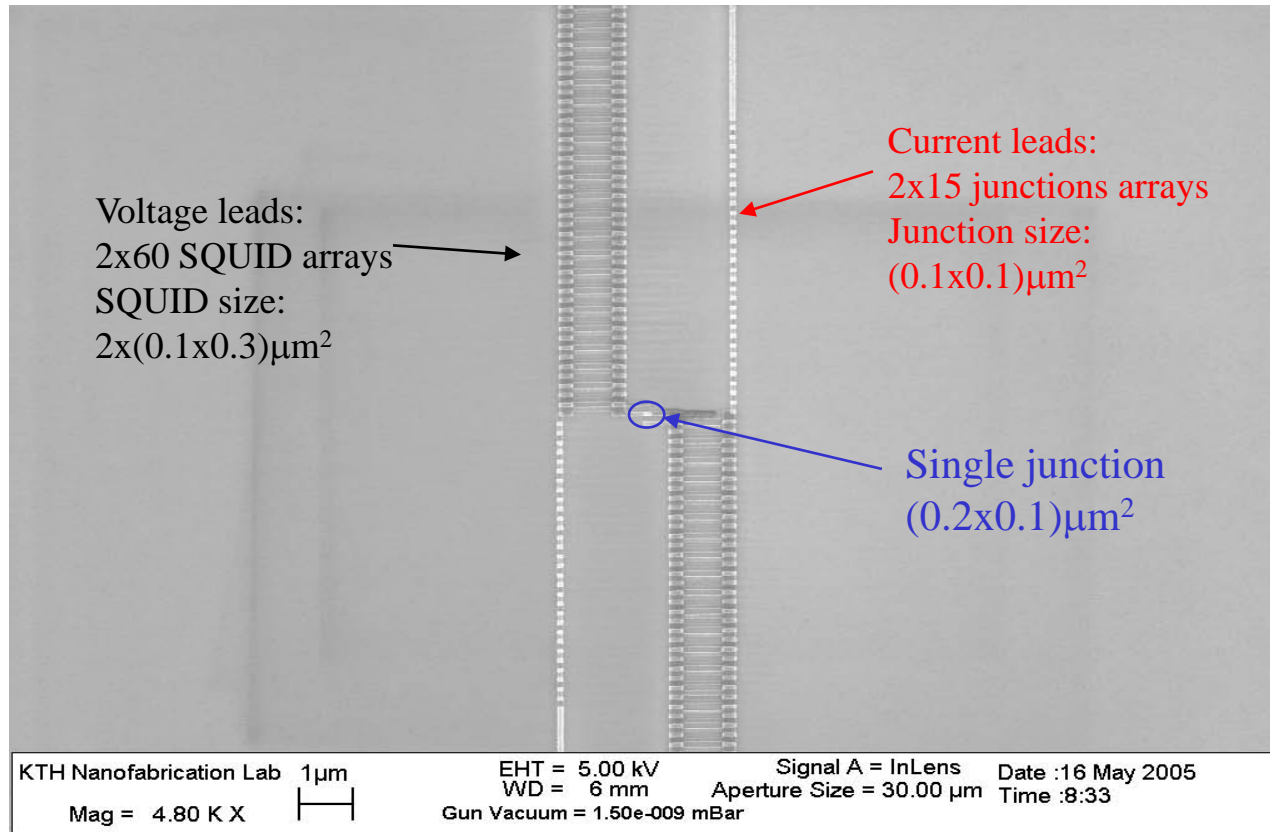


Homepage

- Simple, Functional, not Sexy
- Practical user-oriented
- Manuals, Dos and Don'ts
- Up-to-date with problems, fixes

Josephson Junction Arrays for Circuit QED

David Haviland, Applied Physics, KTH

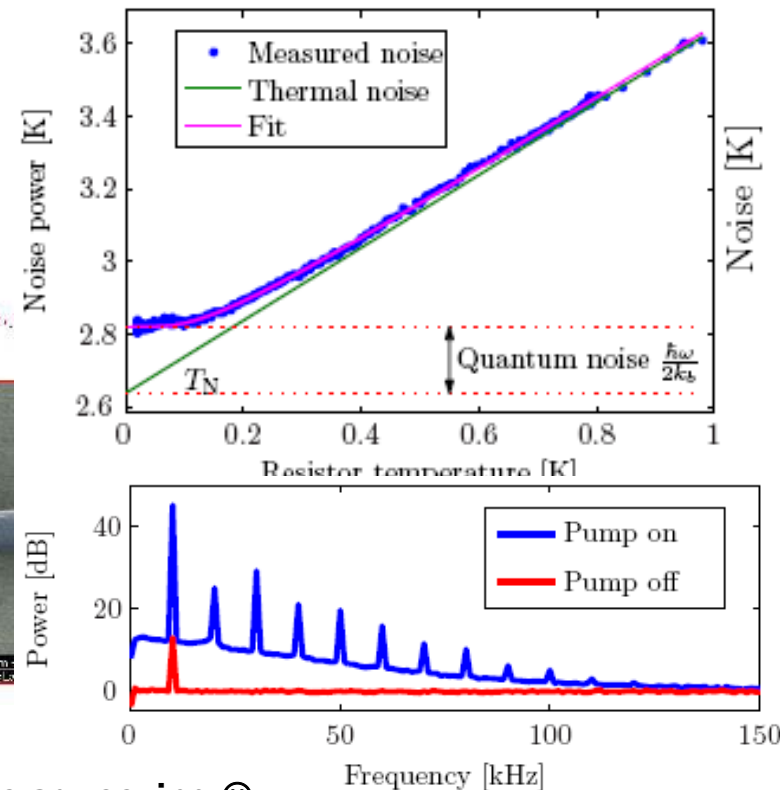
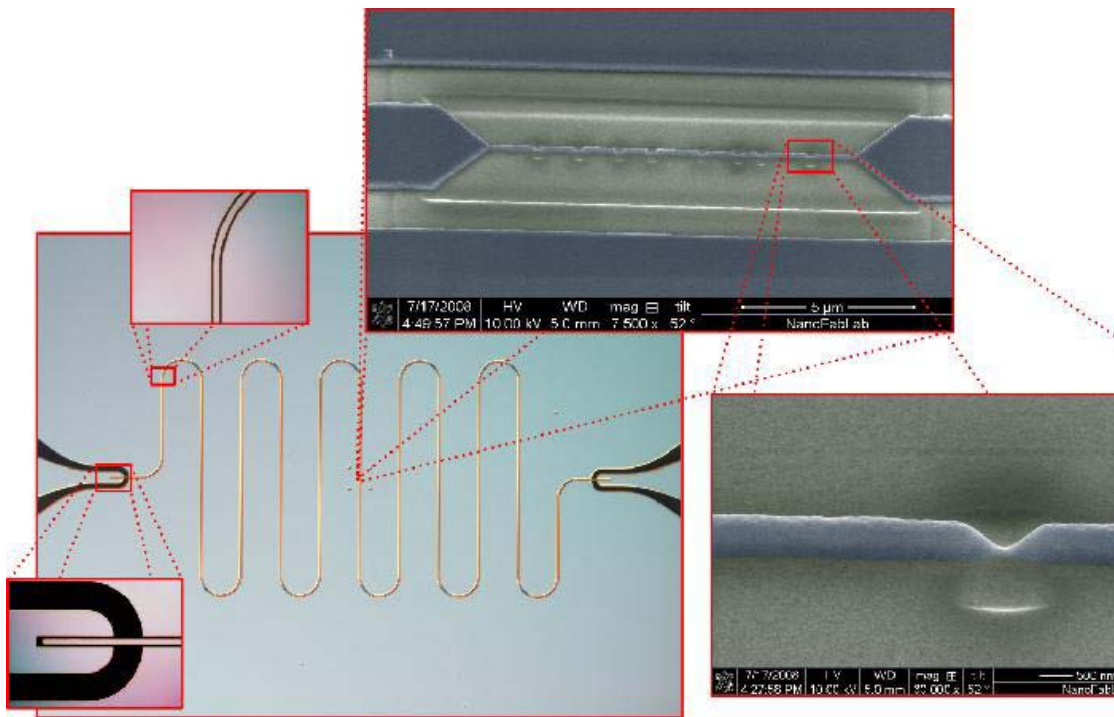


- 800 tunnel junctions in circuit
- SQUID's give tunable Josephson coupling.
- High impedance gives Coulomb blockade of superconducting condensate.

Phase-Charge Duality of a Josephson Junction in a Fluctuating Electromagnetic Environment.
S. Corlevi, W. Guichard, F.W.J. Hekking and D. B. Haviland. Phys. Rev. Lett. **97**, 096802 (2006)

Superconducting microresonators for Parametric amplification and quantum noise squeezing

David Haviland, Applied Physics, KTH Albanova

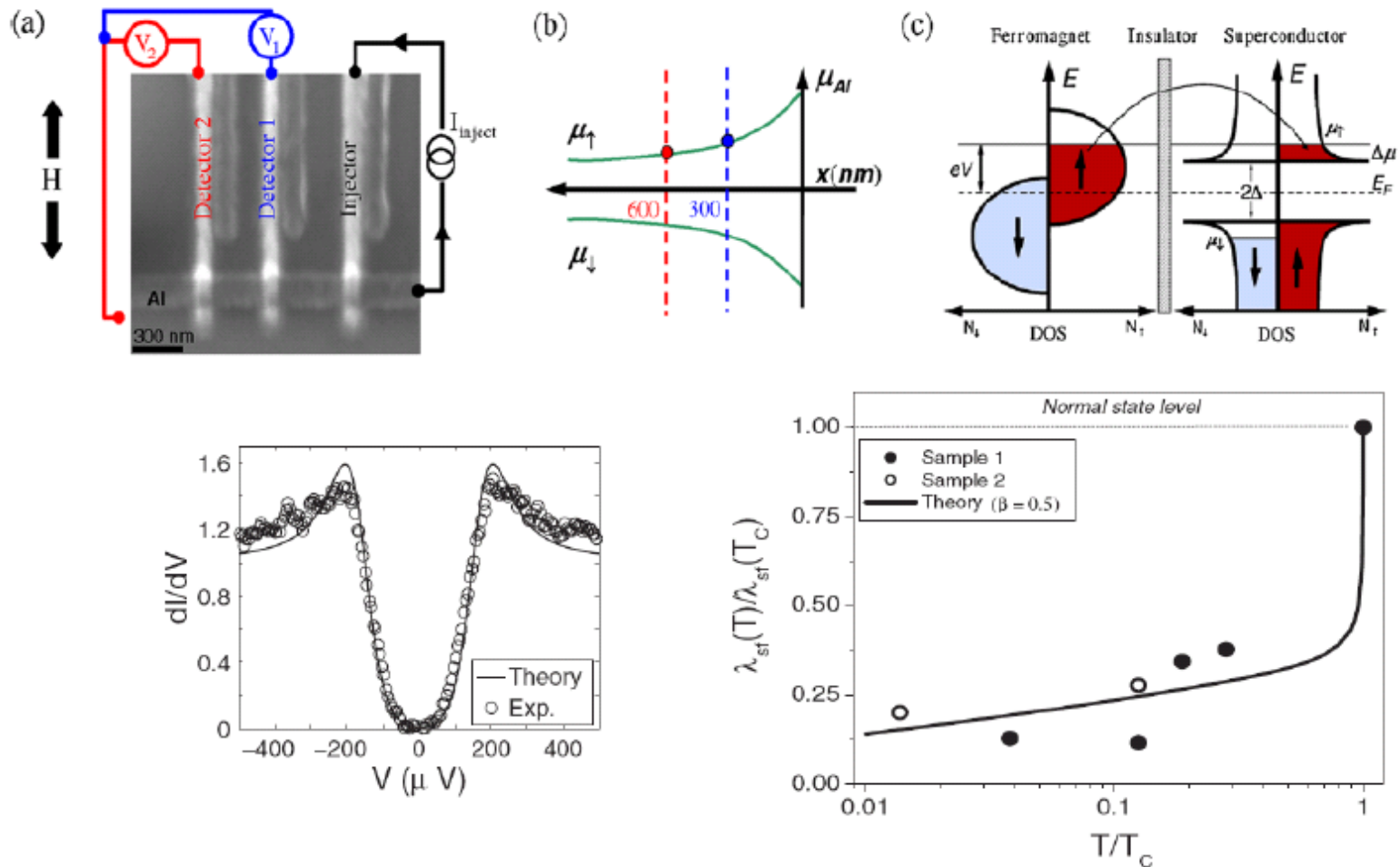


Amplifier Noise temperature 440 mK, no noise squeezing ☹

E. Tholén, A. Ergul, K. Stannigel C. Hutter and D. B. Haviland. Proc. Nobel Symp. on Quantum, Phys. Scr. 014019 (2009)

Spin Transport in Mesoscopic Superconductors

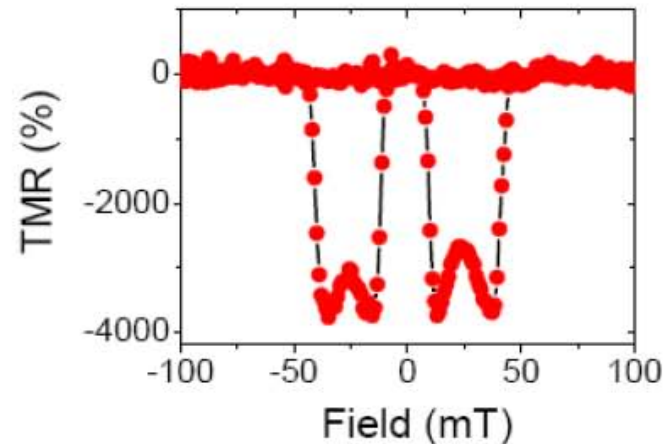
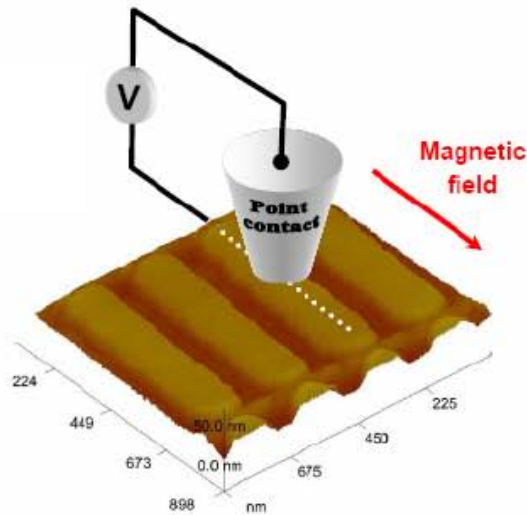
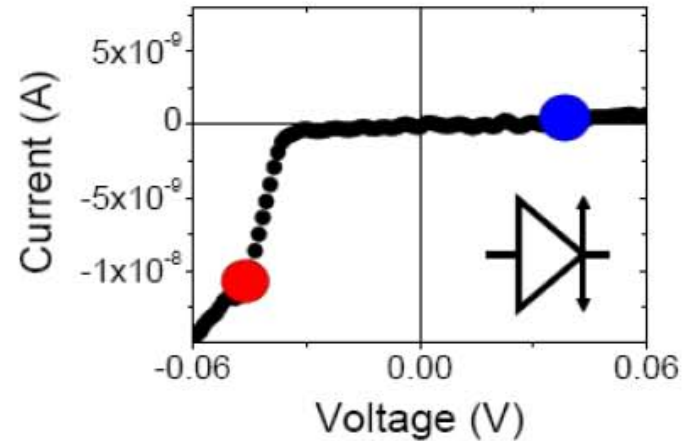
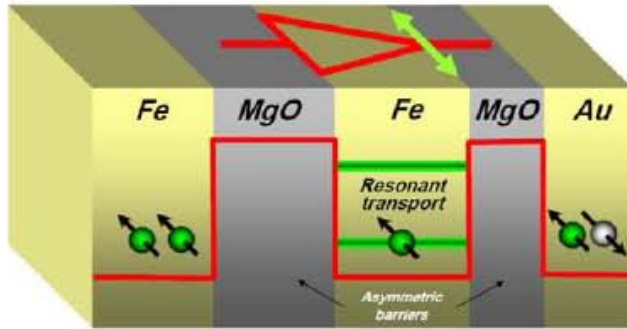
Vladislav Korenivski, Applied Physics, KTH Albanova



Spin injection and relaxation in a mesoscopic superconductor, N. Poli, J. P. Morten, M. Urech, A. Brataas, D. B. Haviland, V. Korenivski, Phys. Rev. Lett. 100 (2008) 136601

Spin Diode

Vladislav Korenivski, Applied Physics, KTH Albanova

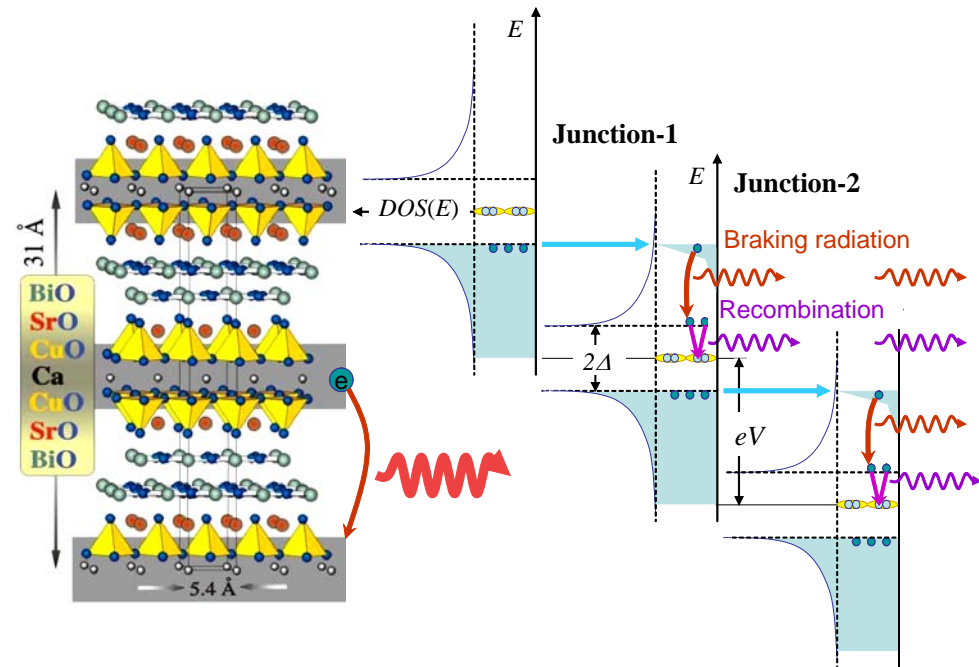
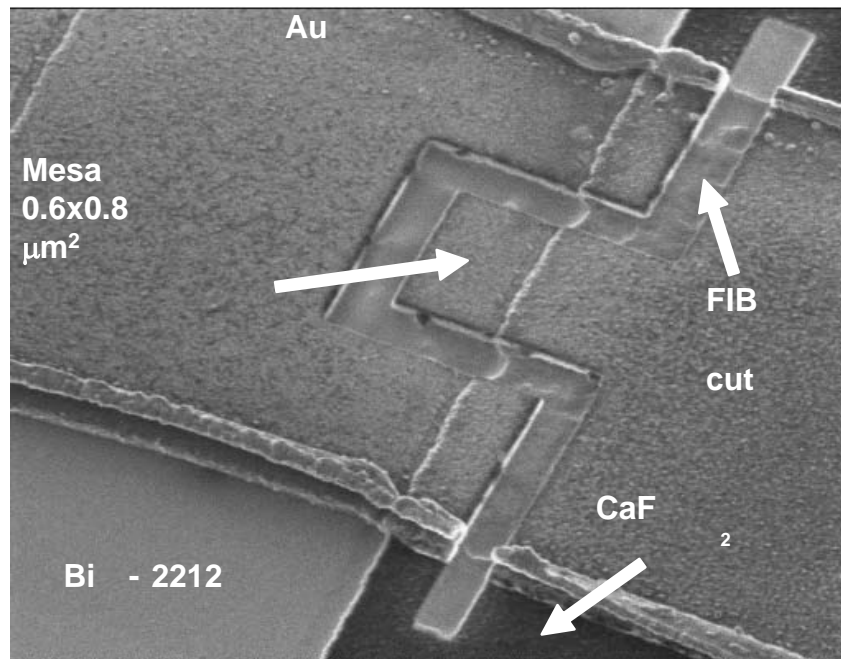


Spin Diode Based on Fe/MgO Double Tunnel Junction, A. Iovan, S. Andersson, Yu. G. Naidyuk, A. Vedyayev, B. Dieny, V. Korenivski, Nano Letters 8 (2008) 805

Intrinsic tunneling in high T_c superconductors and natural atomic superlattices

Vladimir Krasnov, Dept. Physics, SU Albanova

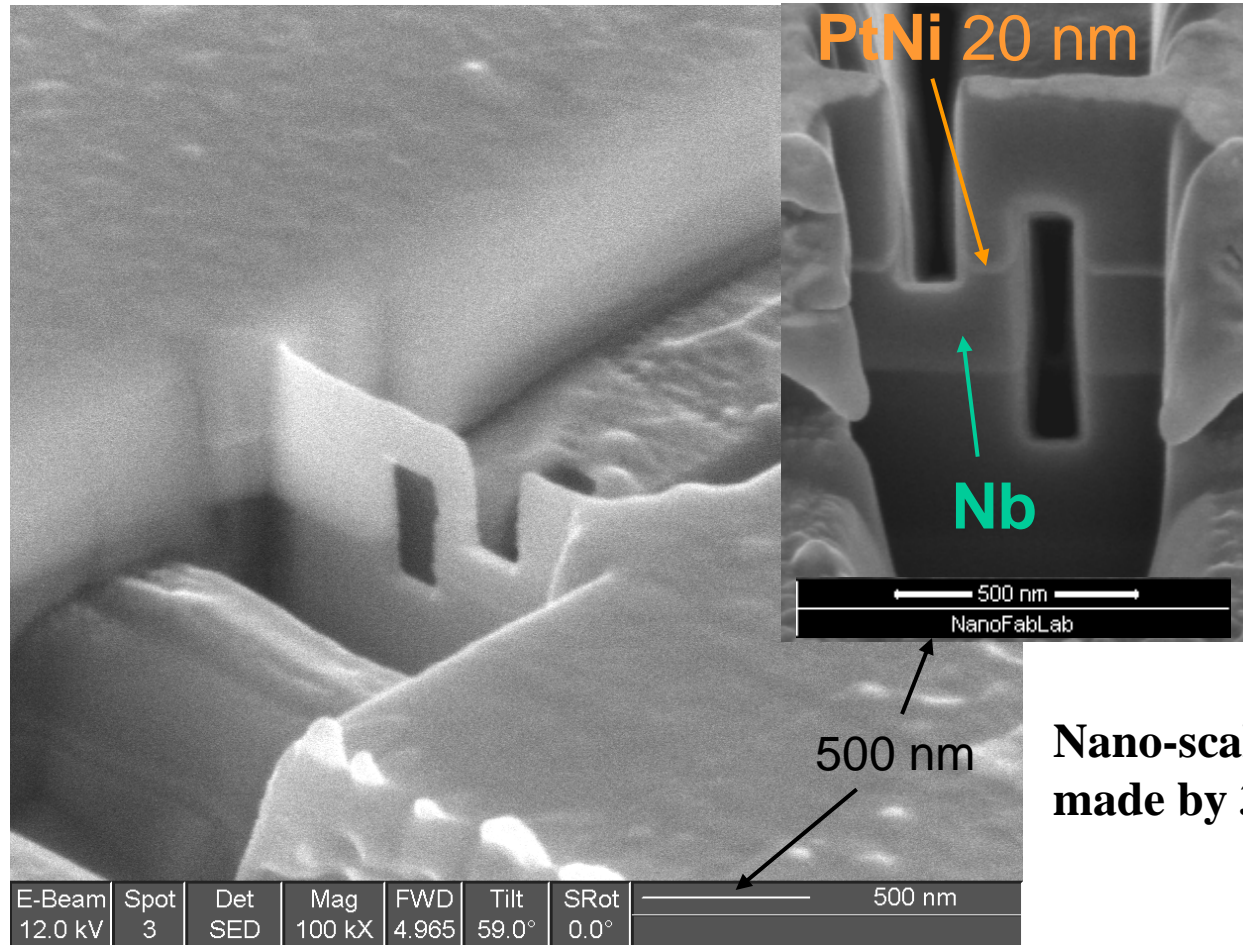
Quantum cascade phenomenon in $\text{Bi}_2\text{Sr}_2\text{CaCu}_2\text{O}_8$ single crystals



V. Krasnov, Phys. Rev. Lett. 97, 257003 (2006)

Hybrid Superconductor-Ferromagnet Components for Quantum Electronics

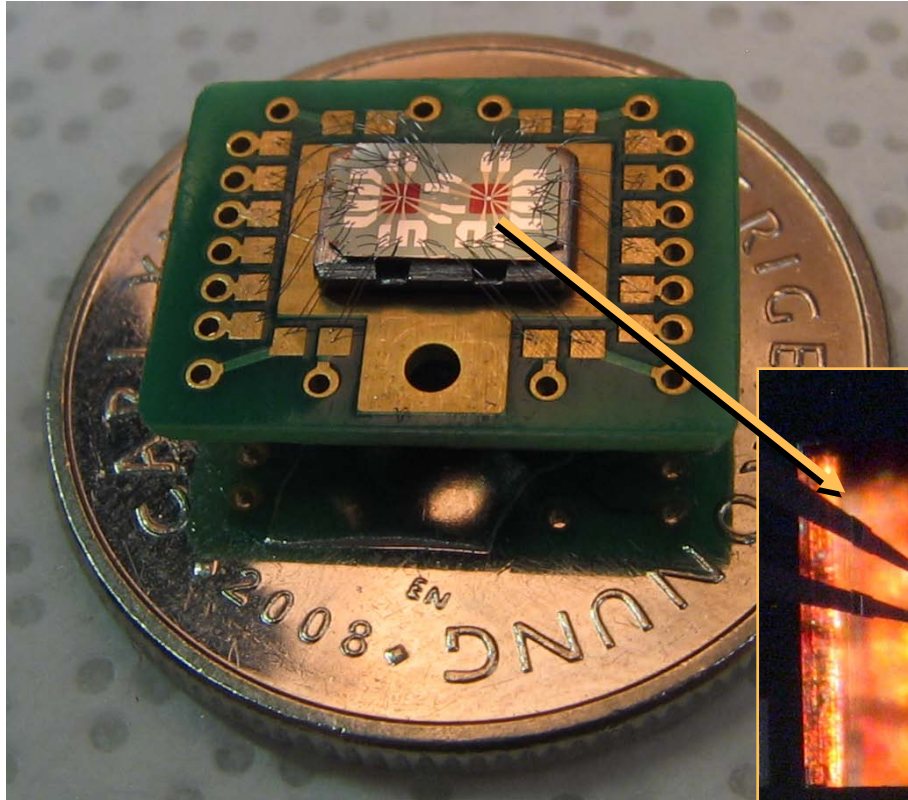
Vladimir Krasnov, Dept. Physics, SU Albanova



**Nano-scale SFS junctions
made by 3D FIB sculpturing**

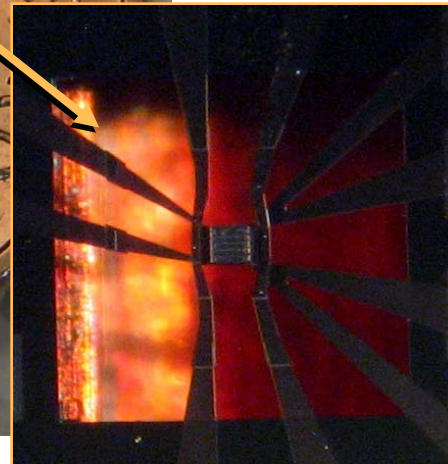
Nanocalorimetry for thin films and mg to sub-ug crystals

Andreas Rydh, Department of Physics, Stockholm University



Specific heat capacity

- AC, relaxation methods
- Differential setup
- Sub-K to 400 K
- Temp. scan 100 K within cell
- Resolution: 1 in 10^4 to 10^5



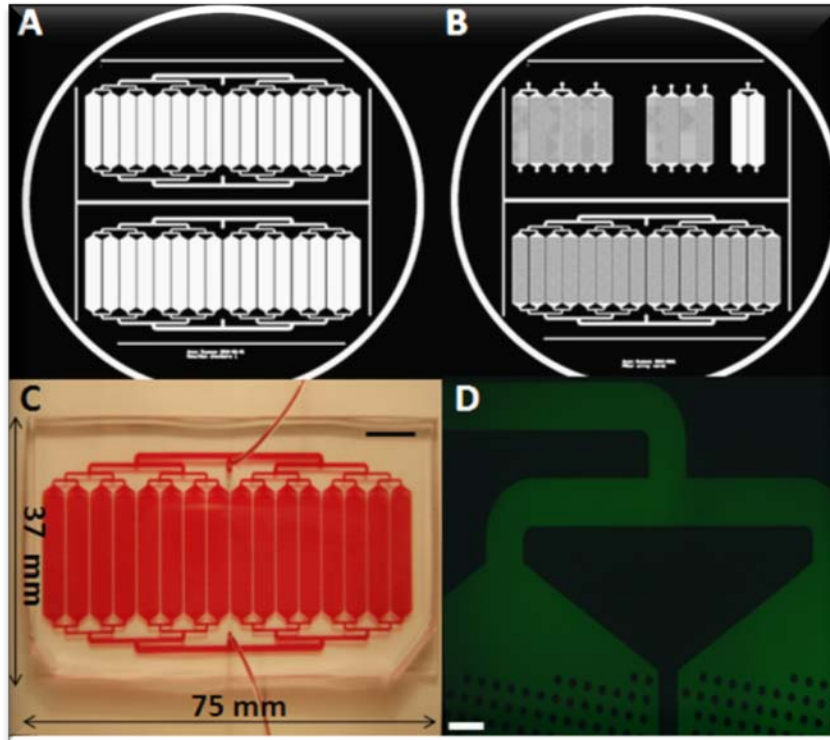
Si_3N_4 : 150 nm
area 1 x 1 mm²
30-50 nm layers

Membrane-based calorimetry for studies of sub-microgram samples

S. Tagliati, A. Rydh, R. Xie et al., Journal of Physics: Conference Series **150**, 052256 (2009).

Microfluidic devices for blood diagnostics

Aman Russom, Applied Physics, KTH



(A-B) Mask designs, and (C-D) PDMS based microfluidic devices functionalized with antibodies. Scale: 250 μ m

- Microfluidic based cell capturing assay
- Parallel-plate immunoassay devices
- Application: capturing of white blood cells and bacteria from blood

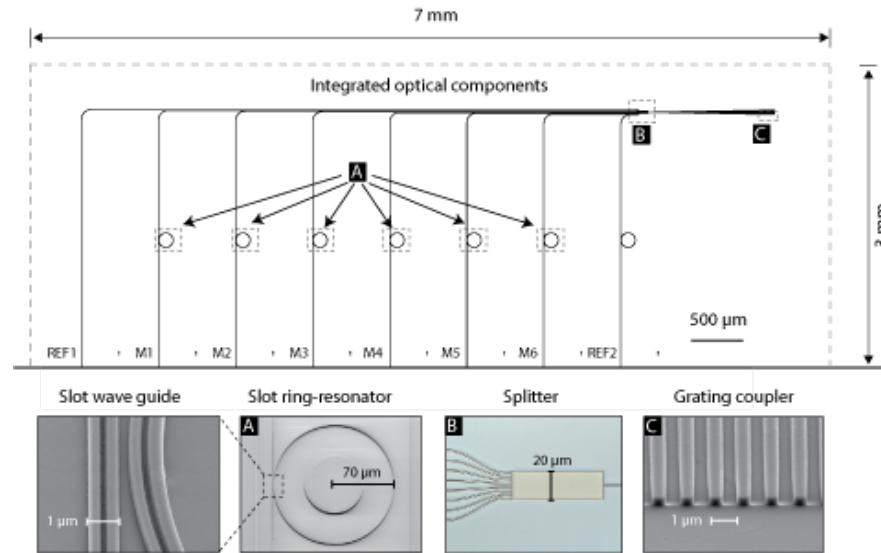
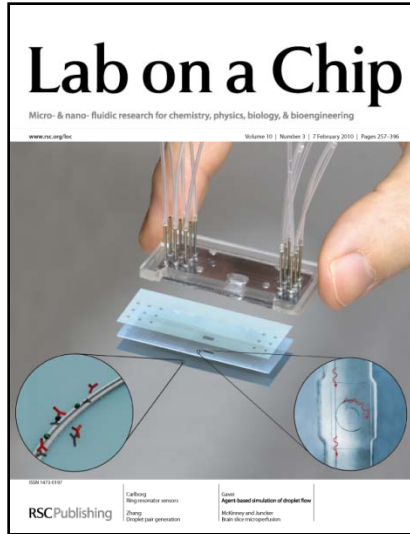
Dean-coupled inertial focusing for ultra-high throughput particle filtration.

S. Ardabili, J. Gantelius, J. Kowalewski, H. Brismar and A. Russom.

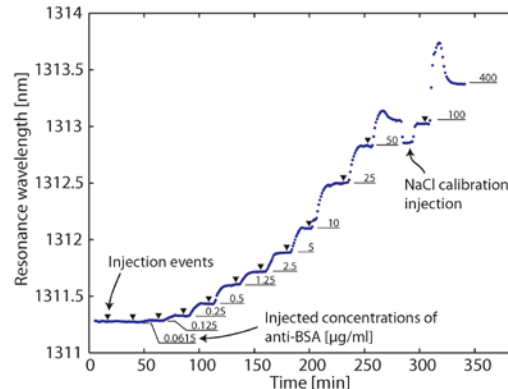
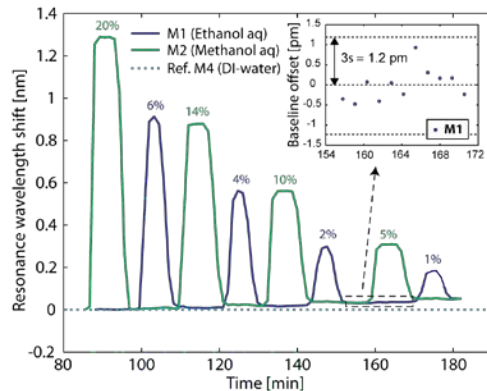
Micro Total Analysis Systems, Groningen Netherlands, Oct 2010. (accepted)

Optical Ring Resonator Biosensor Arrays

Goran Stemme, Microsystem Technology Lab, KTH



- Sensor array for multiplex **label-free biosensing**
- Concurrent **real-time measurement** of up to 6 biomarkers
- Integrated microfluidic sample handling
- Surface mass density detection limit **0.9 pg/mm²**



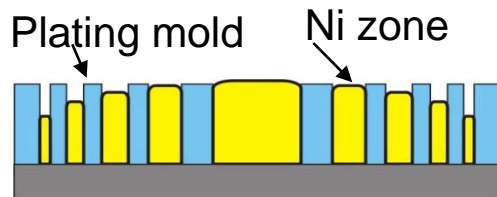
"A packaged optical slot-waveguide ring resonator sensor array for multiplex label-free assays in labs-on-chips". **Carlborg, Gylfason, Sohlström, Stemme, W. Van der Wijngaart et al., Lab on a Chip, 10, 281, (2010)**

X-ray diffractive optics

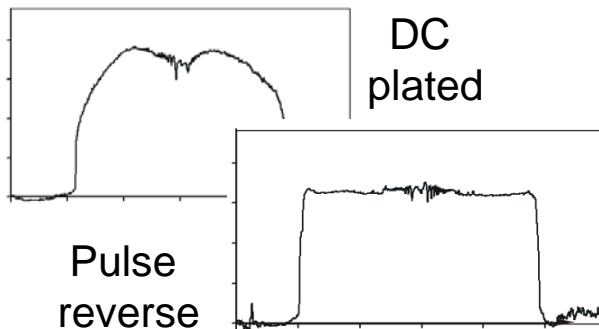
Hans Hertz, Applied Phys. KTH Albanova

M. Bertilsson et al., RSI (2007); Holmberg et al, JVST (2006); Lindblom et al, JVST (2006)

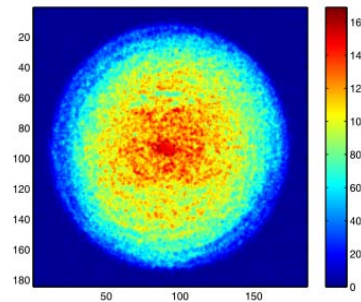
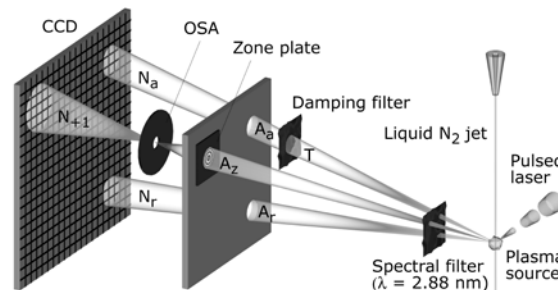
Electro-plating uniformity



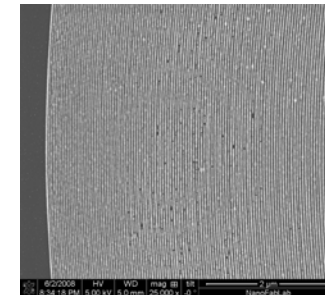
Pulse plating



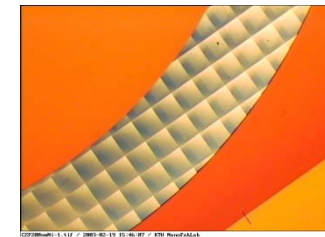
Local diffraction efficiency measurm.



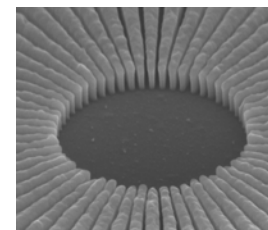
Structures



20-25 nm Ni
zone plates



5 mm diam
condensers



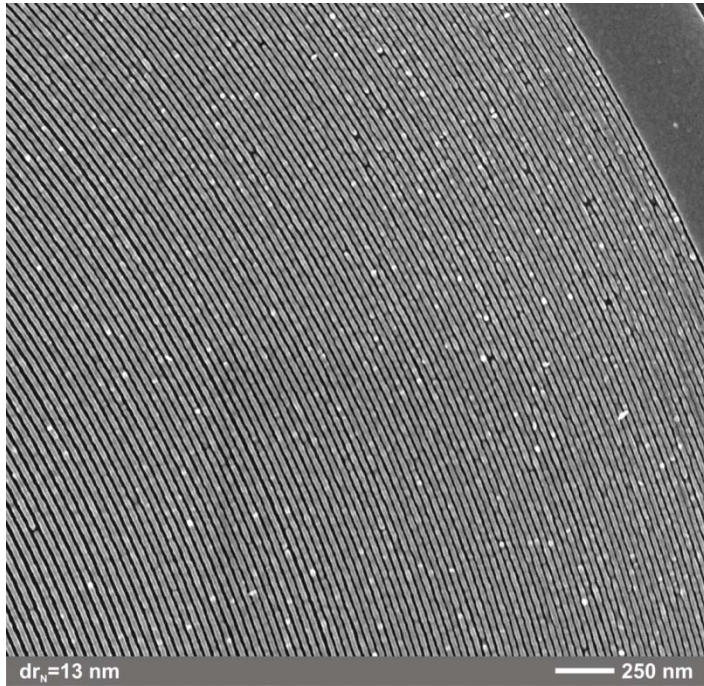
Test patterns

High Resolution EBL

Hans Hertz, Applied Phys. KTH Albanova

Single-write Ni ZP

Reinspach et al., JVST B (2009)



$\varnothing = 19 \mu\text{m}$

$dr_N = 13 \text{ nm}$; $h = 35 \text{ nm}$

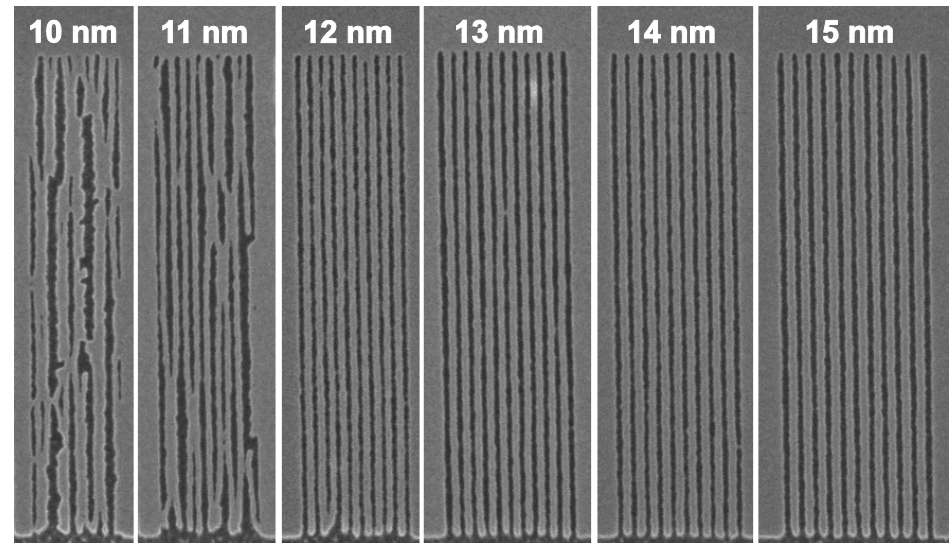
$f = 100 \mu\text{m}$ @ $\lambda = 2.48 \text{ nm}$

Excellent uniformity

Efficiency: 2.7% (15 nm/h=55 nm zp)

Cold development: ZEP in hex acet

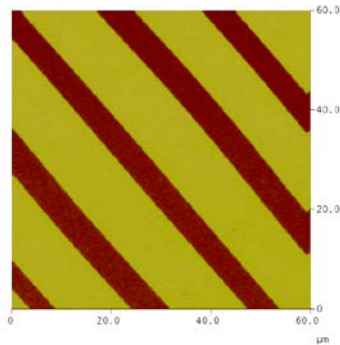
Good Mold stability



Ferroelectric domain engineering for novel optical applications

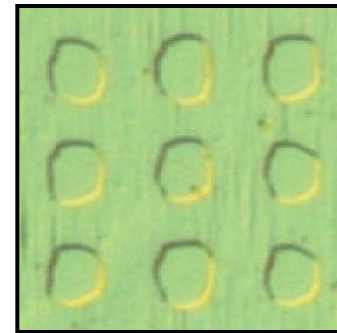
Fredrik Laurell, Applied Physics, KTH Albanova

Micro- and nano-meter ferroelectric domains electrically polled 1 mm bulk ferroelectric crystal



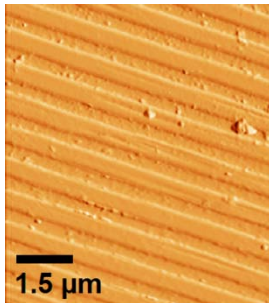
Frequency conversion

$\Lambda = 20 \mu\text{m}$



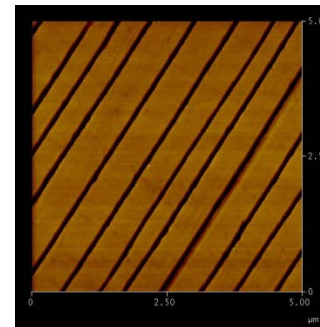
2D nonlinear photonic crystal

$\Lambda = 6.09 \mu\text{m} \times 6 \mu\text{m}$



Electrically addressable Bragg reflectors

$\Lambda = 800 \text{ nm}$



Self-assembled nanostructures

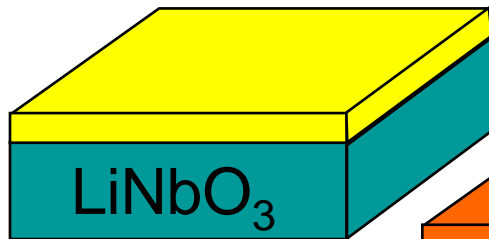
$\Lambda = 500 \text{ nm}$

C.Canalias et al. Appl. Phys. Lett. 86,181105 (2005)

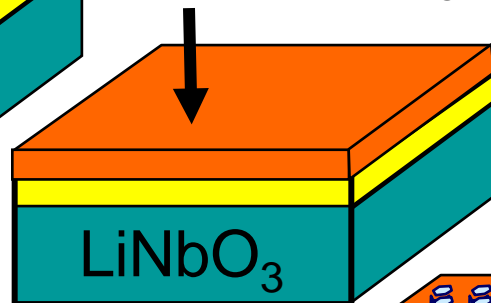
Nonlinear photonic crystals

Fredrik Laurell, Applied Physics, KTH

Metal layer deposition

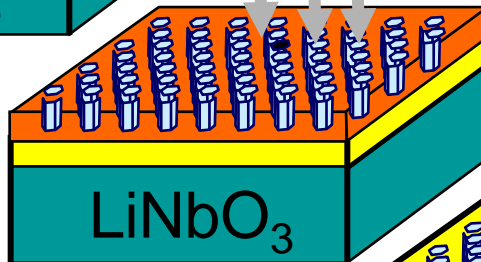


e-beam patterning

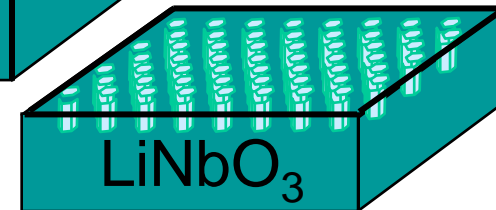
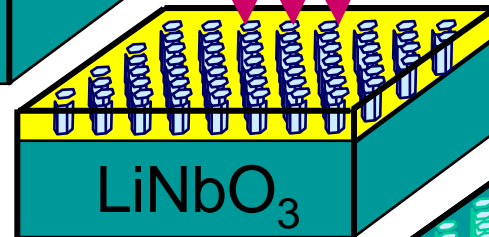


- Charge accumulation in substrate
- Relatively long periodic structures
- Relatively deep LiNbO₃ etch ($\sim 1\mu\text{m}$)

Pattern transfer
resist \rightarrow metal



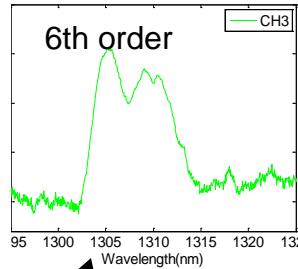
Pattern transfer
metal \rightarrow LiNbO₃



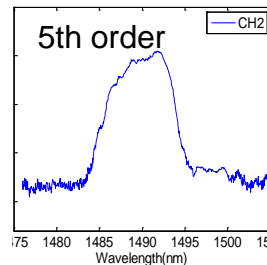
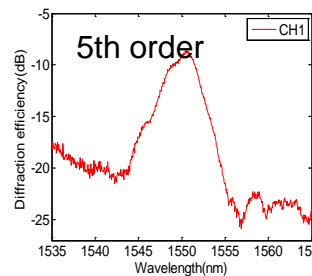
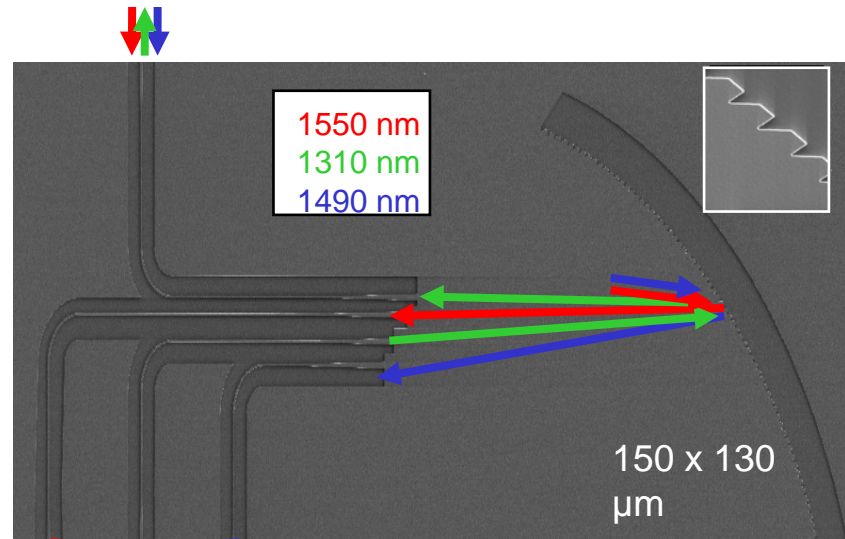
- LiNbO₃ gets charged very easily \rightarrow use intermediate metal masking layer
- LiNbO₃ etches slowly ($\sim 50\text{ nm/min}$ in SF₆ RIE) \rightarrow find conditions for good pattern transfer (mask, RIE, substrate pre-treatment)

SOI cross-order Echelle-grating triplexer

Lech Wosinski, FMI, KTH Kista



Different diffraction orders to cover large spectral range and keep the device compact.



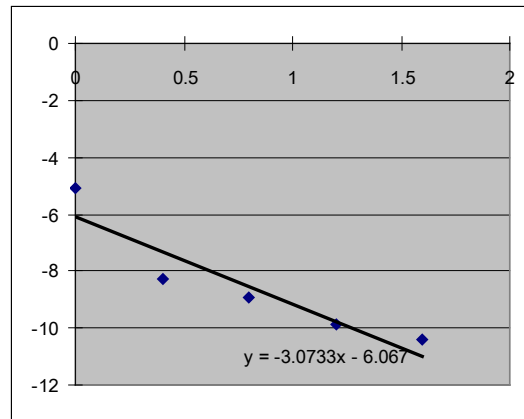
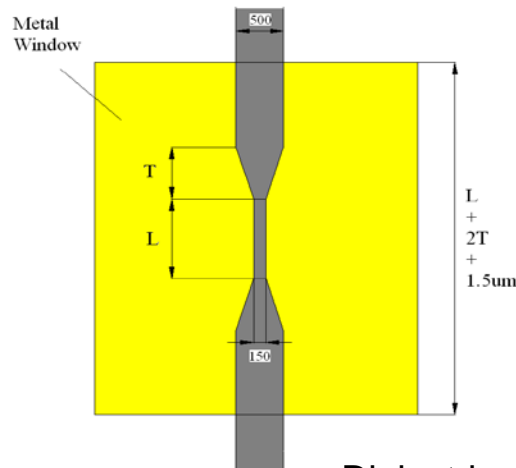
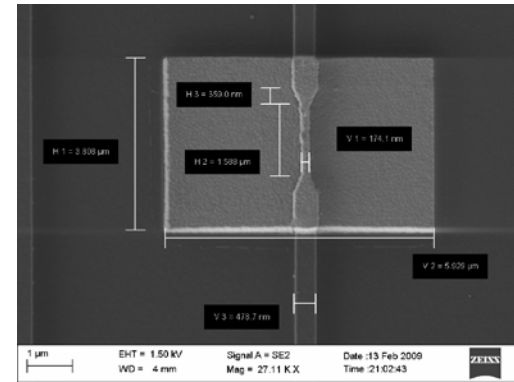
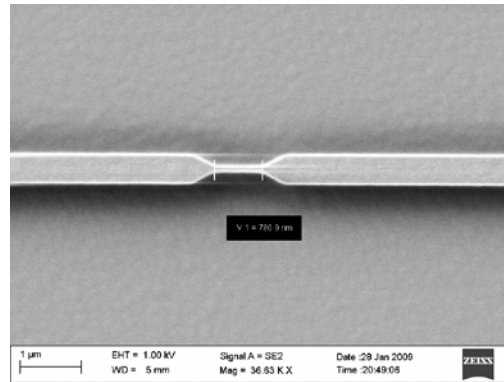
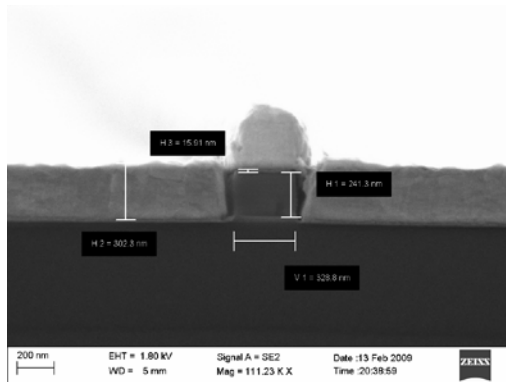
RESULTS:

- crosstalk < 20dB
- loss per channel \approx 11dB

“Experimental demonstration of a cross-order echelle grating triplexer based on an amorphous silicon nanowire platform”, N. Zhu, J. Song, L. Wosinski, S. He and L. Thylen, Optics Letters, Vol. 34, 383-385 (2009).

Plasmonic slot waveguides for photonics

Lech Wosinski, FMI, KTH Kista



RESULTS:

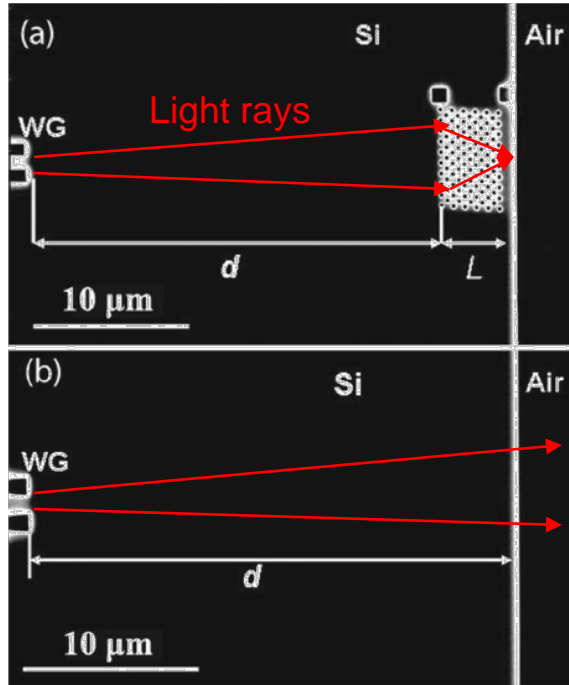
- Propagation loss = $3.0733 \text{ dB}/\mu\text{m}$
- Loss of coupling between 500nm Si waveguide to 500nm Si wg with metal = 2.1 dB/facet
- Loss of taper/350nm = 0.4 dB/taper

Dielectric and plasmonic slot waveguides for photonic integration

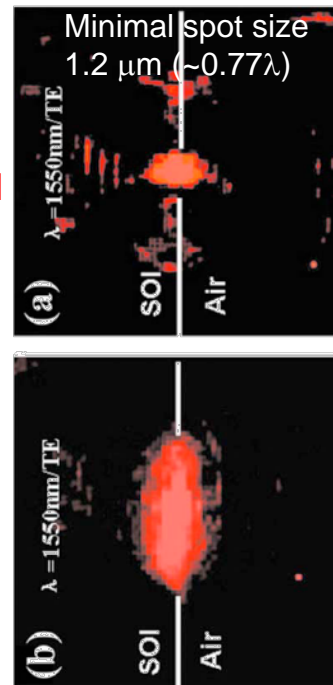
B.Jaskorzynska, Y. Song, N. Zhu, Z. Wang, M. Qiu and L. Wosinski, ICTON 2009, Procs of the IEEE.

Focusing light by negative refraction

Min Qiu, Photonics, KTH



Light focused



Light spot size at the device edge

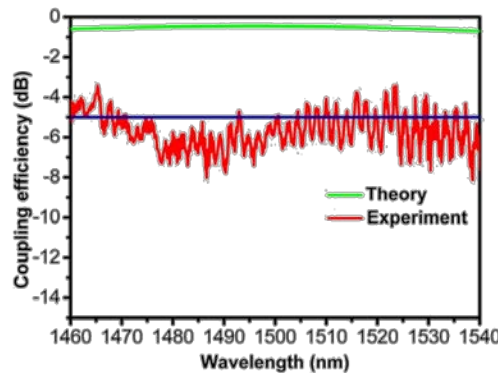
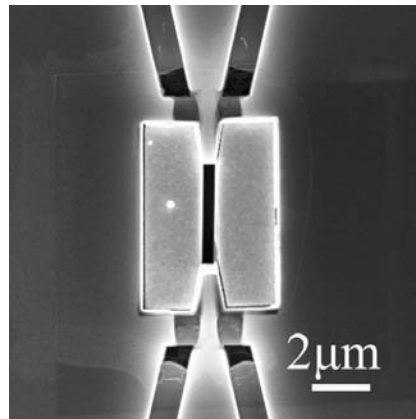
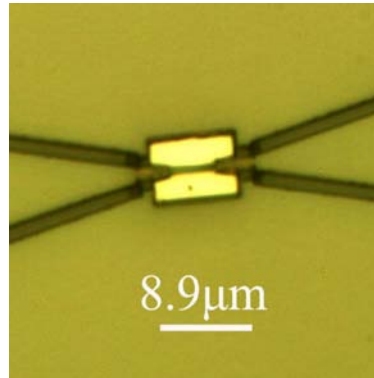
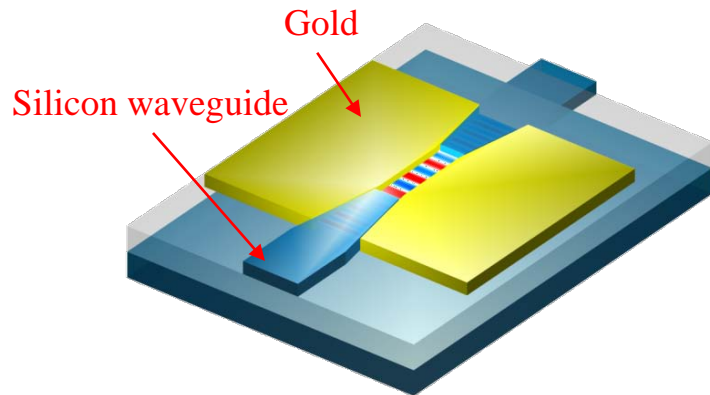
- Near infra-red light focused demonstrated by a two-dimensional silicon photonic crystal flat lens
- Photonic crystal slab fabricated on a silicon-on-insulator substrate by focused-ion-beam direct milling
- Sub-wavelength focusing observed

Direct characterization of focusing light by negative refraction in a photonic crystal flat lens

J. Tian, M. Yan, M. Qiu, C. G. Ribbing, Y.-Z. Liu, D.-Z. Zhang, and Z.-Y. Li, Appl. Phys. Lett. **93**, 191114 (2008)

Broadband plasmonic waveguide coupler

Min Qiu, Photonics, KTH



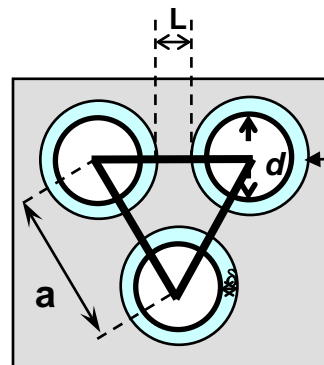
- Plasmonic coupler is composed of a tapered silicon strip waveguide and a subwavelength metal gap waveguide
- 35% coupling efficiency per facet demonstrated
- A crucial step for hybrid integration of plasmonic components with conventional dielectric components

Broadband high-efficiency surface-plasmon-polariton coupler with silicon-metal interface
J. Tian, S. Yu, W. Yan, and M. Qiu, Appl. Phys. Lett. **95**, 013504 (2009)

Carrier Transport in 2D-Photonic Crystals

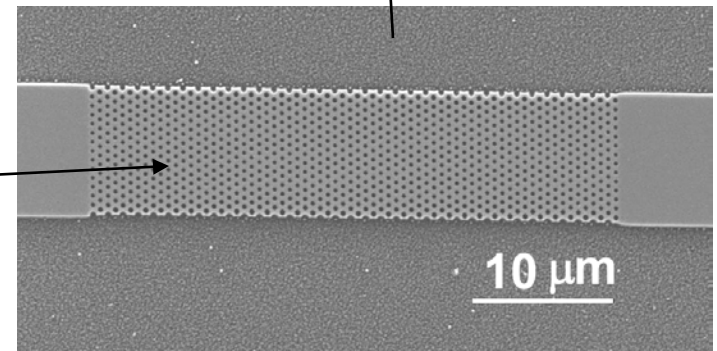
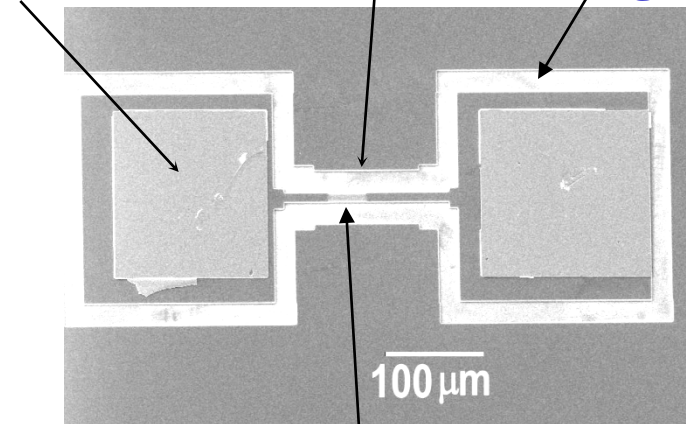
Srinivasan Anand, MAP, KTH Kista

- InP active material, 2D photonic crystal
- Electrically addressed Photonic crystal devices:
- Electrical contact schemes
- Pattern dependent electrical properties



Depleted region
Width δ


Contact pad Conducting channel Isolating trench

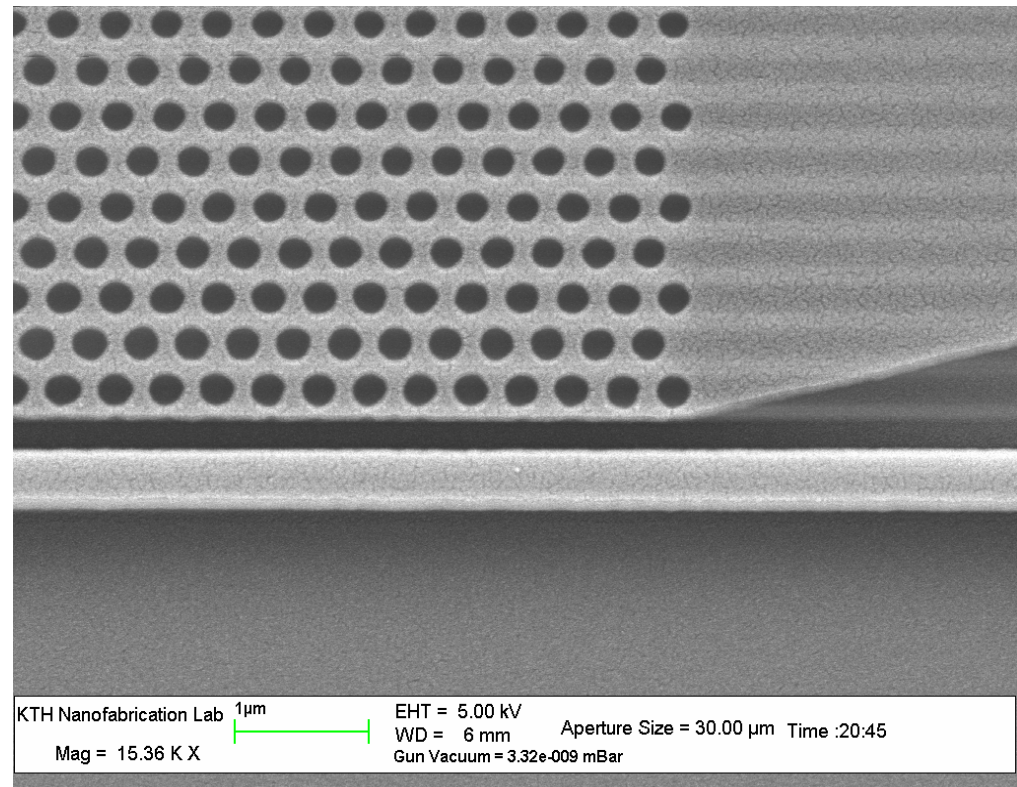
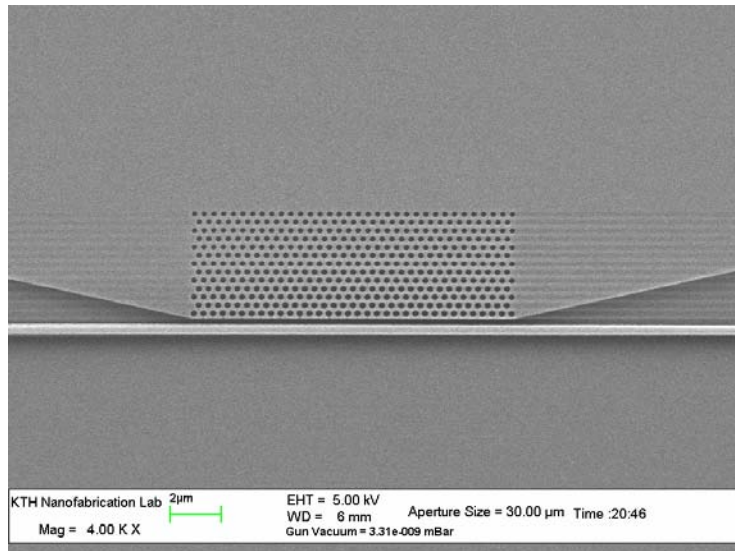


A.Berrier, M. Mulot, G. Malm, M. Östling and S. Anand, Proc. SPIE Optics and Photonics'06

Surface-mode cavity in 2D photonic crystal slabs

Min Qiu, MAP, KTH Kista

- PECVD growth of amorphous silicon on silica structure
 - E-beam lithography
 - ICP etching
 - Application for high Q optical filter
- 
- A grayscale micrograph showing a periodic array of circular holes (vias) in a thin film. The holes are arranged in a regular grid pattern. The surrounding material appears as a light gray background, and the holes are darker gray. The edges of the holes are slightly irregular, suggesting an etched structure.

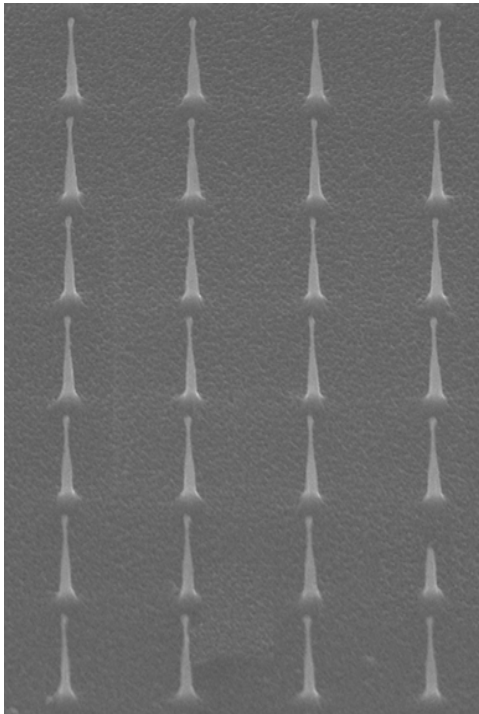


Ziyang Zhang, Matteo Dainese, Lech Wosinski, and Min Qiu, Accepted Appl. Phys. Lett. 2006

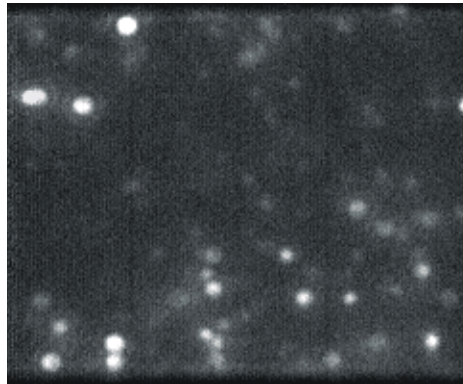
Silicon quantum dots

J. Linnros, MAP, KTH Kista

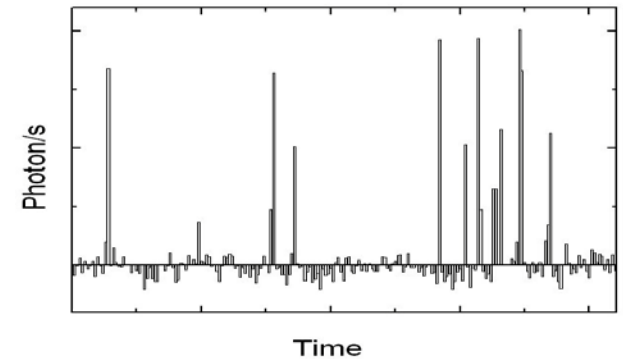
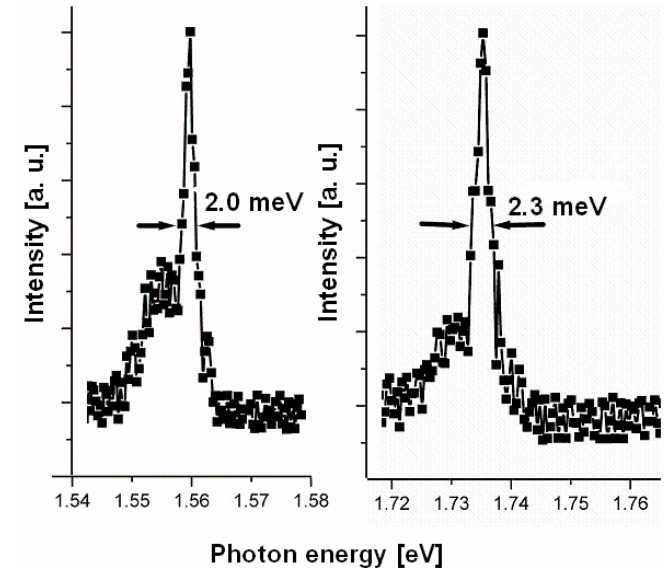
- E-beam lithography
- Size reduction by oxidation
- Removal of oxide



Sharp Photo
Luminescence
emmission lines



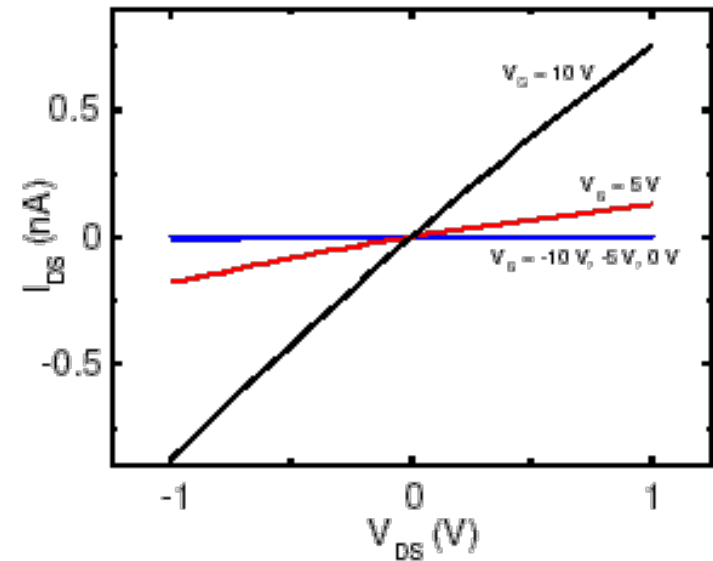
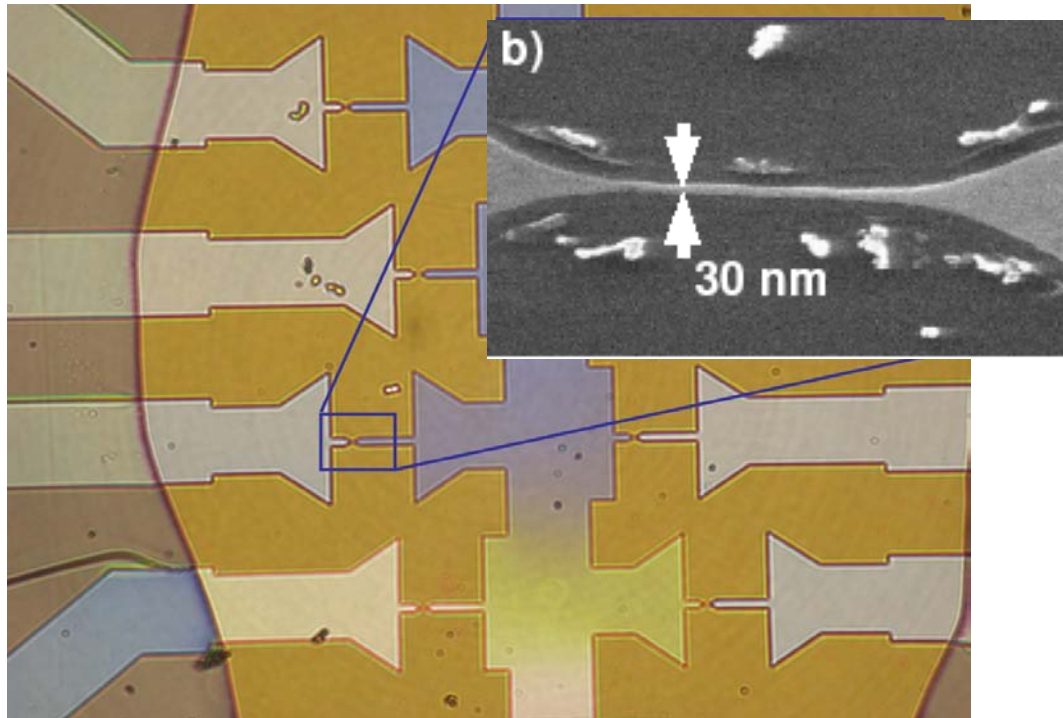
On/Off Blinking



Sychugov et al. PRL 94, 087405 (2005), Sychugov et al. PRB 71, 115331 (2005)

Silicon nanowires

J. Linnros, MAP, KTH Kista



Transistor characteristics

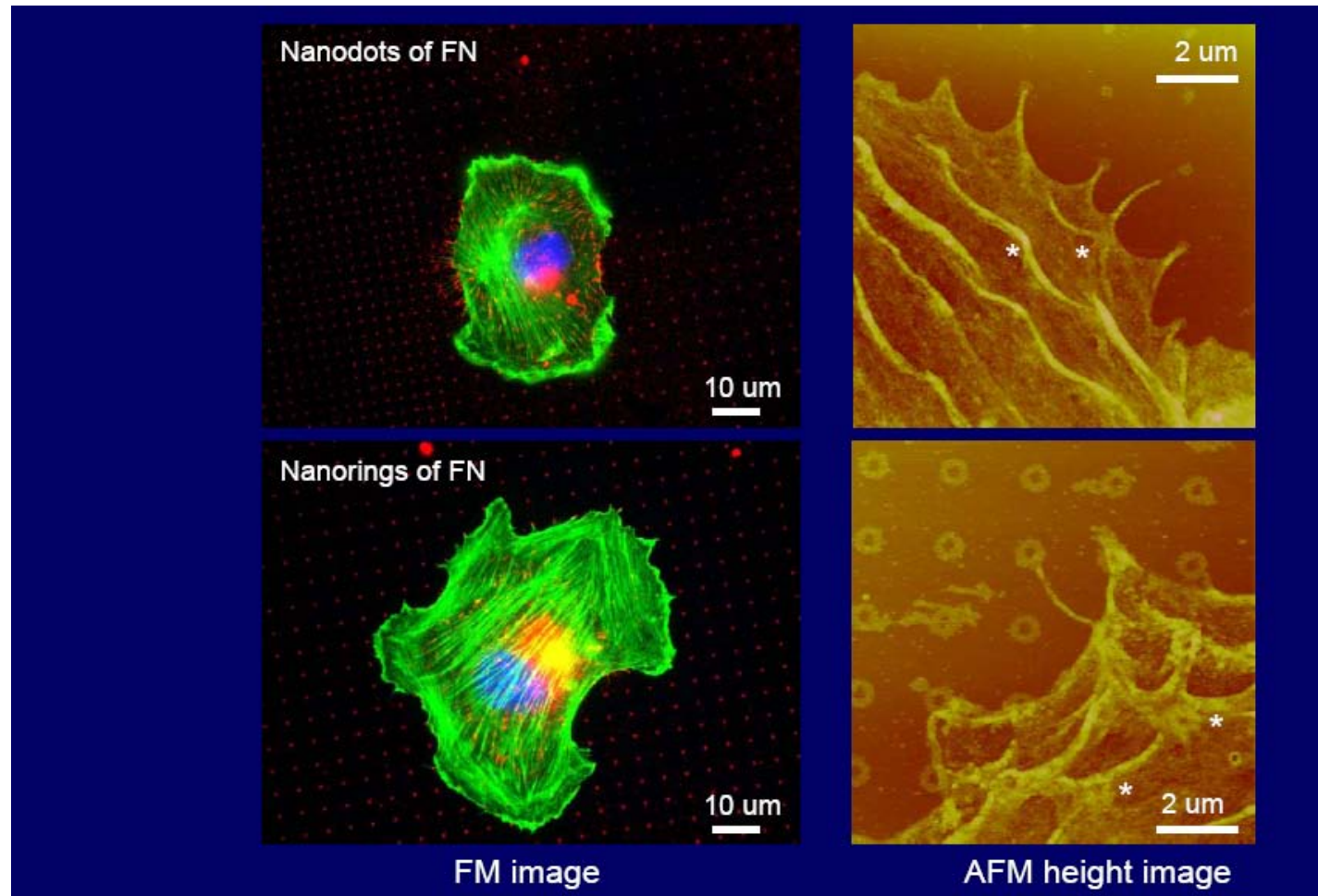
- Chip, SOI technology
- Electron beam lithography
- Size-reduction by
- electrochemical etching

Juhasz et al., NanoLett 5, 275 (2005)



Nano-Patterned Protein templates for cell growth studies

David Haviland, Applied Physics, KTH Albanova

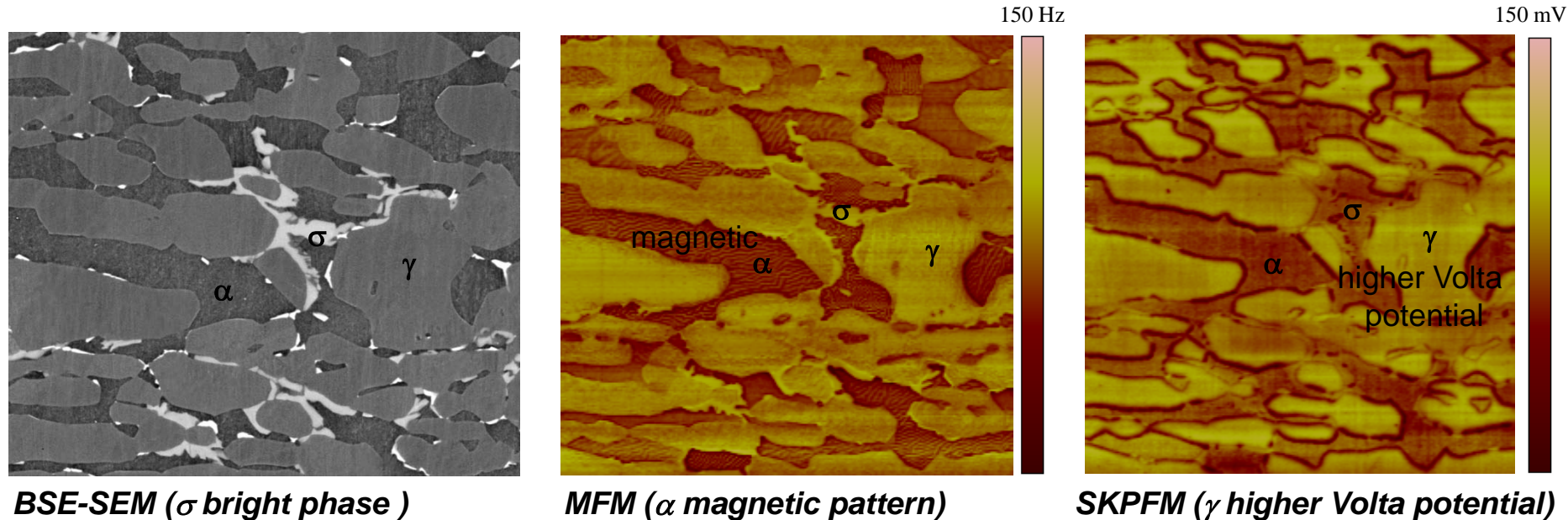


Modulation of Cell Adhesion Complexes by Surface Protein Patterns, D. Pesen and D. B. Haviland, ACS Appl. Mater. Interfaces, 1, 543-548 (2009). (featured article on cover)

Characterization of relative nobility of phases in duplex stainless steel

Jinshan Pan, Surface & Corrosion Science, KTH

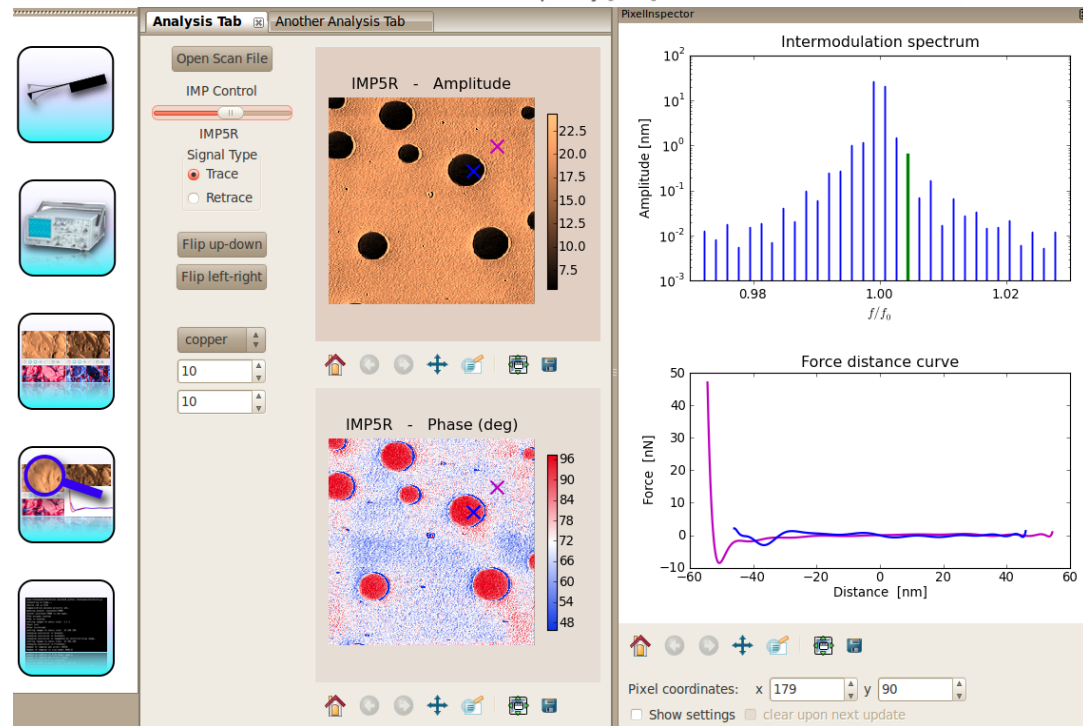
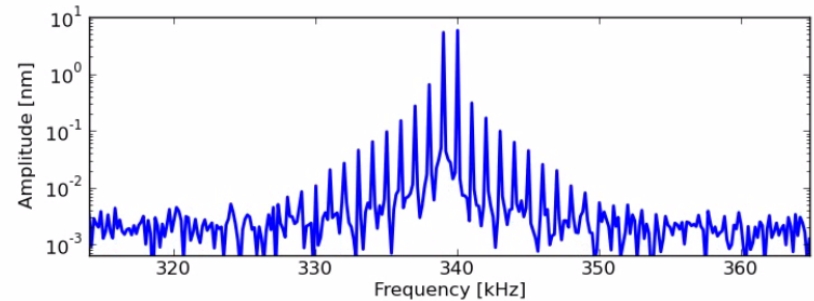
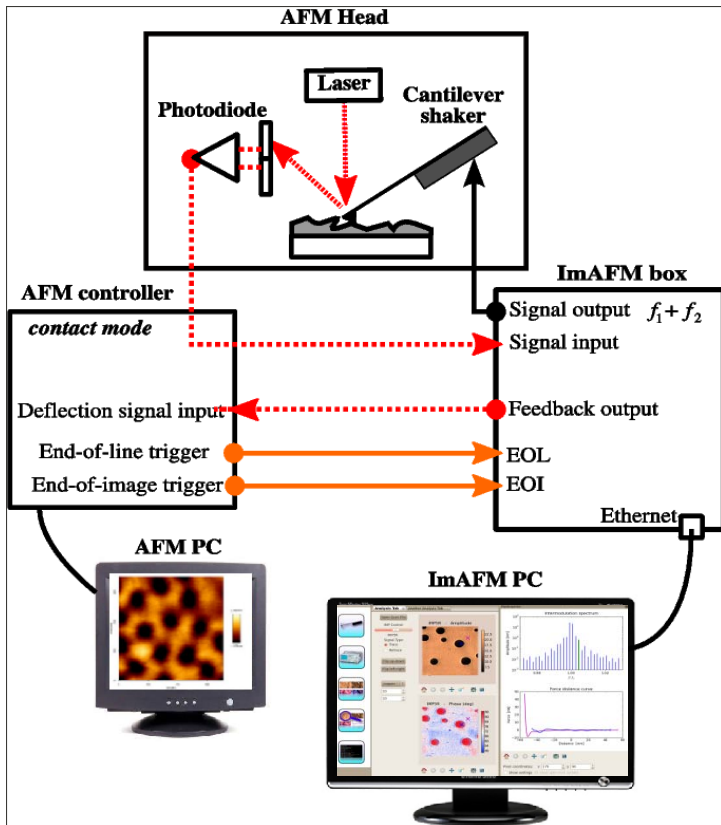
Duplex stainless steel 2205, heat treated, contains ferrite (α), austenite (γ) and sigma (σ) phases



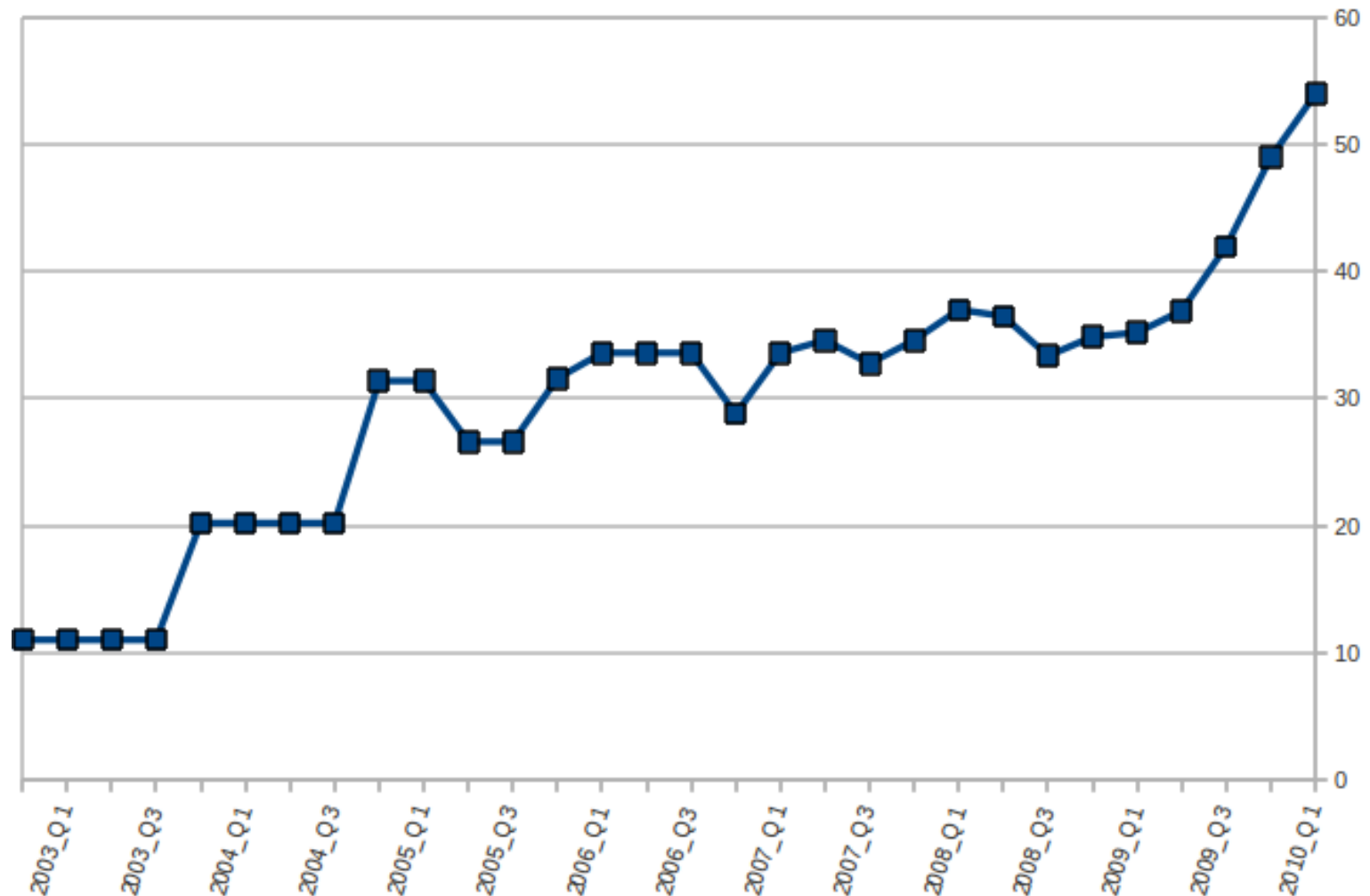
Characterization of phases in duplex stainless steel by magnetic force microscopy scanning Kelvin probe force microscopy
N. Sathirachinda, R. Gubner, J. Pan, U. Kivisäkk, *Electrochem. Solid-State Lett.*, **11**, C42-C45 (2008)

Intermodulation Atomic Force Microscopy

David Haviland, Applied Physics, KTH Albanova



Albanova Nanolab users
number of users paying base fee, by quarter

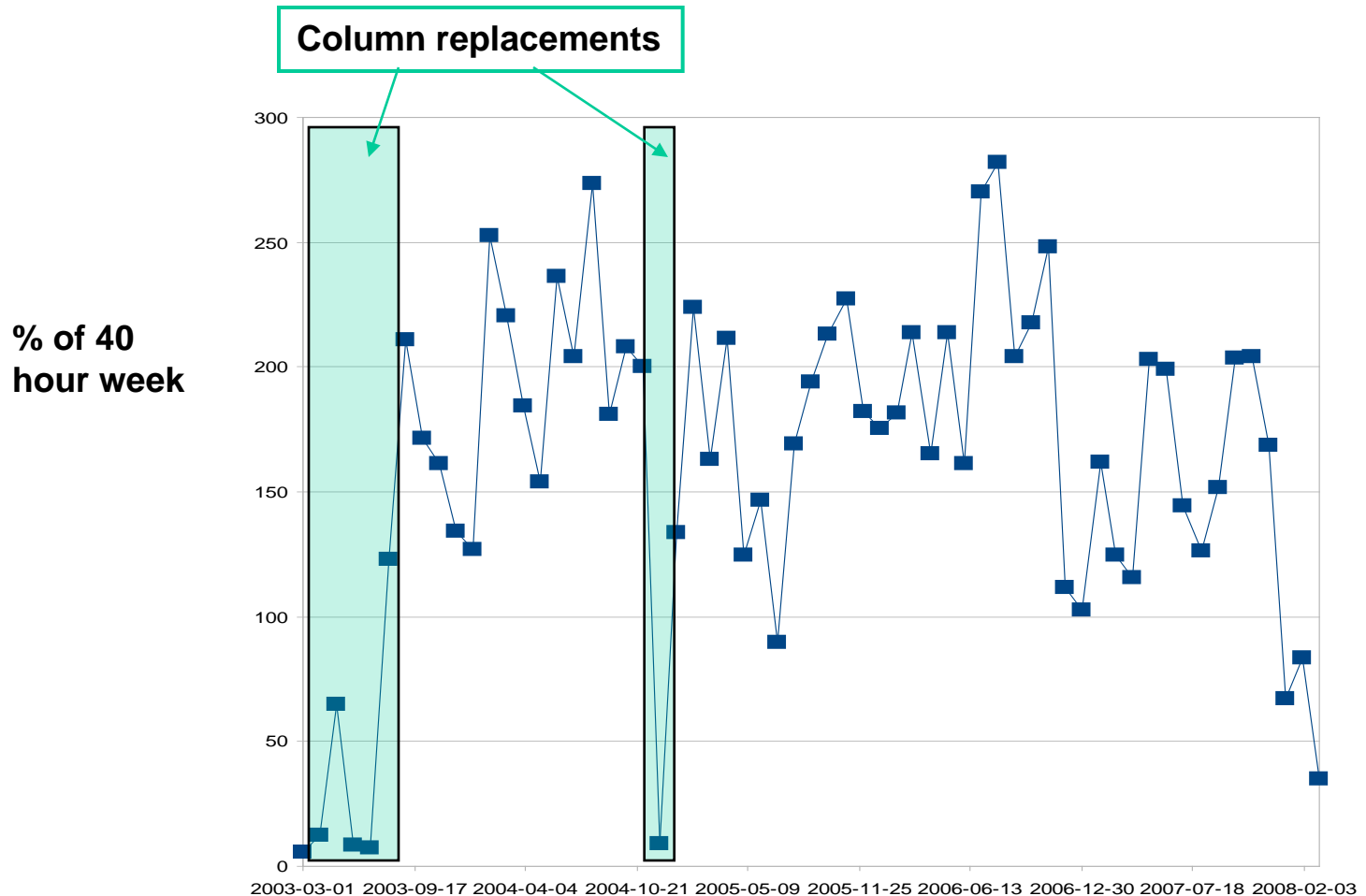


Productivity as of April 2008

See Appendix 1 of Activity report

- PhD thesis - 21 completed, 24 in progress
- Master thesis - 8
- Post Docs – 6
- Companies - 4

E-beam usage:



Low cost, minimal bureaucracy

2010 Budget

| | |
|--------------------------------|------------|
| Total Costs | -3.2 M SEK |
| Subsidies (KTH Aphys, SU phys) | +1.1 M SEK |
| User fees | +2.1 M SEK |

User fees: 54 paying base fee (2010_Q2)

- base fee 6250 SEK per user per quarter year
- time charge on e-beam, SEM/FIB, mask align, AFM

Low cost structure because we are slim: 1 FTE technician salary, everyone helps with maintenance, education, weekly user meetings.

Access Example: E-beam Lithography

- Internal (Inst. pays subsidy)
 - 6250 SEK /quarter base fee
 - 275 SEK/hr machine time
 - ½ price after 6pm, free midnight to 7am
- External (Inst. does not pay subsidy)
 - 6250 SEK/quarter base fee
 - 600 SEK/hr machine time
 - ½ price after 6pm, free midnight to 7am

Outlook

- Can accommodate 2 systems, ca 10 users with current space
- Need to increase technical staff
- Develop SPM – more users from Chemistry
- Part of Aphys Labs (Laser, Bio-Image, Cell growth)
- Incubator for small companies
 - Xcilium
 - Intermodulation Products